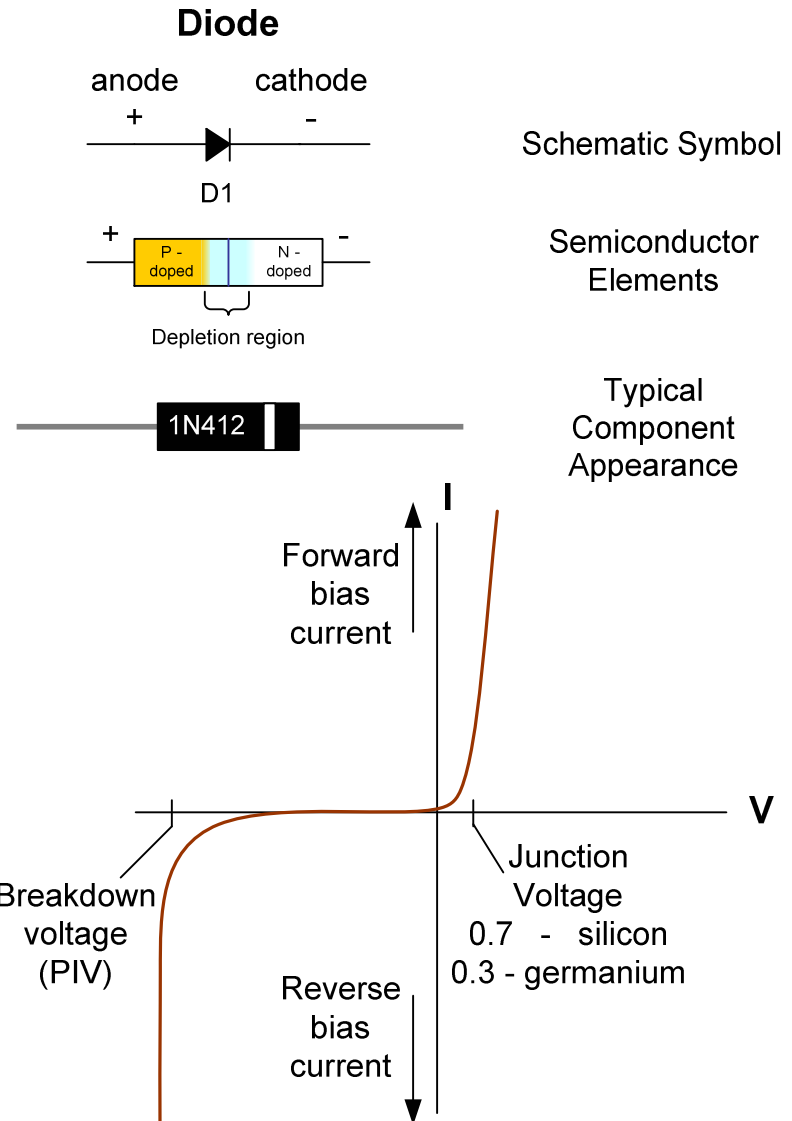


Semiconductor devices

Diodes and transistors

Diode devices

- Check valve behavior
 - Diffusion at the PN junction of P into N and N into P causes a depleted non-conductive region
 - Depletion is enhanced by reverse bias
 - Depletion is broken down by forward bias
- When forward biased
 - High current flow junction voltage
- When reverse biased
 - Very low current flow unless above peak inverse voltage (PIV) (damaging to rectifying diodes, OK for zeners)



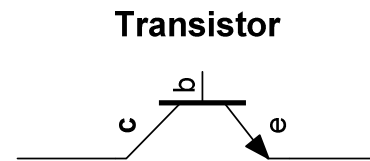
Transistor devices

- Construction

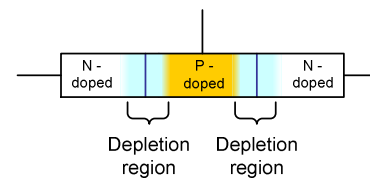
- Analogous to two diodes with a p-p (for an NPN device), or an n-n connection (for a PNP device)
- Connections
 - Collector
 - Base
 - Emitter

- Nature of the device (NPN)

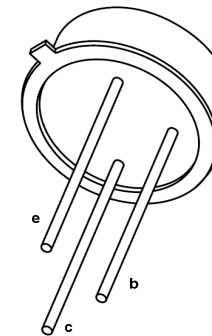
- Reverse bias on the C-B junction and a moderate forward bias on the B-E junction causes current flow from C to E. Current is proportional to gain times B-E current in the linear range of the device
- PNP requires reverse polarities and has reverse current flow.



Schematic Symbol



Semiconductor Elements



Typical Component Appearance

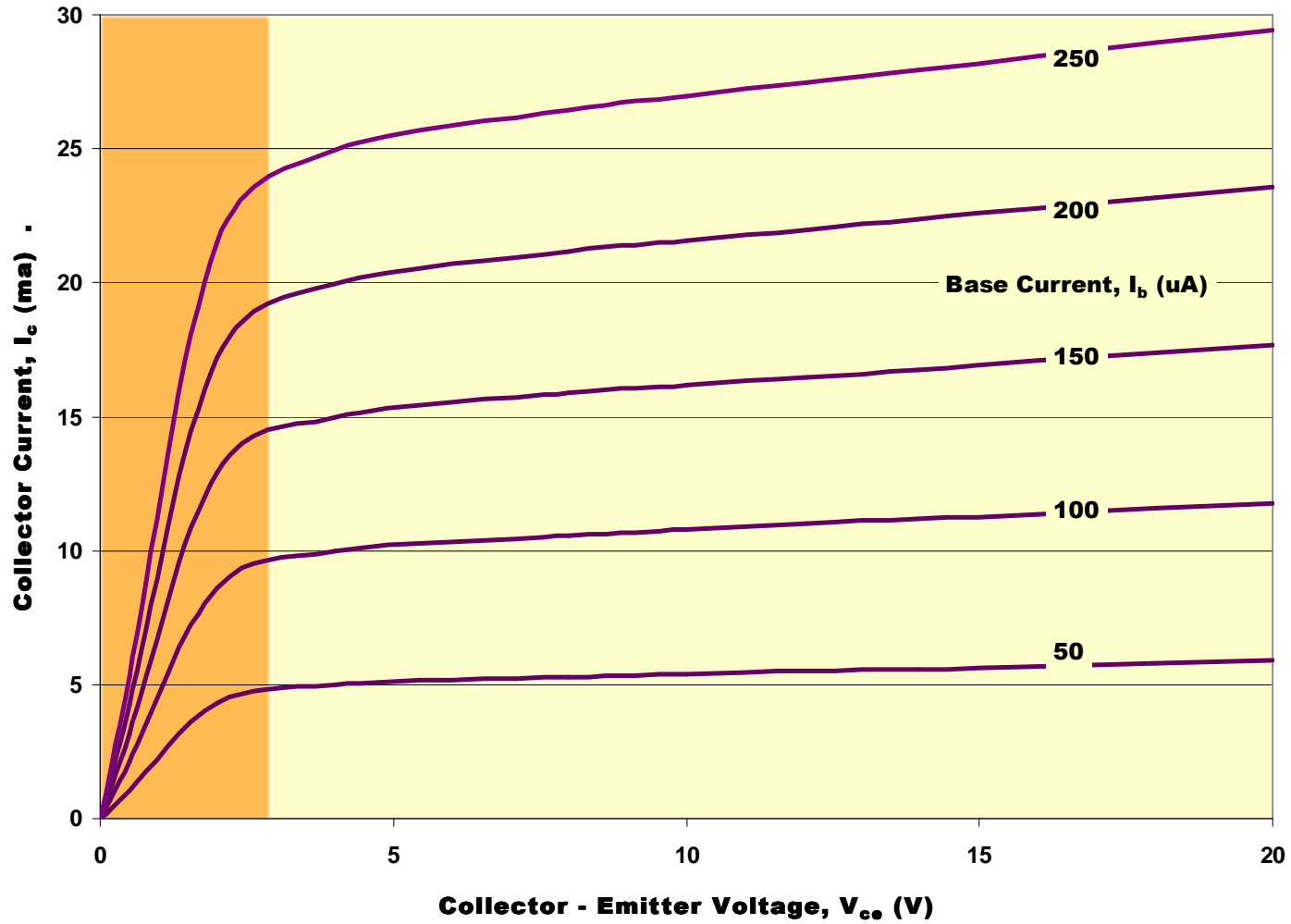
Transistor devices

- The physics of the device are complicated
 - Describes current passing through the reverse biased E-B Junction
- Critical characteristics
 - Primary descriptive equation is the current gain relating base to collector current

$$h_{FE} = \frac{I_C}{I_B}$$

- Typically DC current gain (h_{fe}) will be 10-400
- Care must be taken to assure the transistor currents are controlled and the device is never biased in a way that would allow a destructive level of current.
- Voltage differences must also be controlled below maximums.
- Un-intentional biasing reverse to the normal application may destroy the device.
- Thermal dissipation must be managed

Graphical depiction of amplification

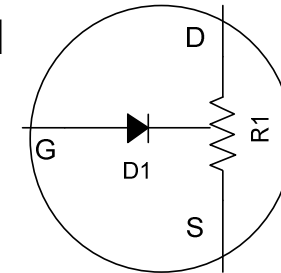


Junction Field Effect Transistors

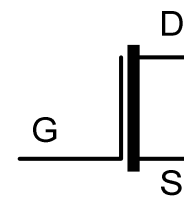
- Transconductance is controlled by V_{GS}
- Pinched gate technology
- High gate impedance
- Heavily used for power drive circuits
- Application:
 - S-D current is reduced for higher reverse gate bias voltage.
 - R proportional to V_{GS}
 - V_{GS} must be reverse bias to avoid damaging the device

- Field Effect Functional Model

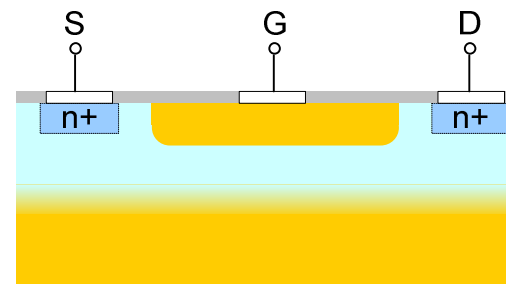
– N Channel



- Schematic symbol



- Semiconductor elements



Transistor switching circuits

- Application of a transistor to provide increased switched current

- Transistor selection

- Maximum collector current: must be greater than the load current.

$$I_{C_{\max}} > \frac{V_L}{R_L}$$

- Minimum current gain: h_{FE} should be at least five times the load current divided by the maximum output current from the chip.

- Base resistor size:

$$R_b = \frac{h_{FE} V_c}{5I_C}$$



MOSFET

